IN THE CLAIMS

1. (Currently Amended) A mirror comprising a multi-layer thin film, wherein said multi-layer thin film comprises a first layer and a second layer,

said first layer has a reflection surface plane,

said second layer has a contact plane with a substrate, and an angle between said reflection surface plane and

said contact plane is 45° or equal to an angle between (100) plane orientation and a (111) plane orientation in a silicon crystal, and

said mirror has a concave portion which is filled with a material.

- 2. (Original) The mirror according to claim 1, wherein said mirror comprises one of a gold film, a lamination film of rhodium film nickel film gold film, a lamination film of platinum film nickel film gold film, a lamination film of palladium film nickel film gold film, a lamination film of gold film nickel film gold film, a lamination film of chrome film nickel film gold film, a photosensitive polyimide film, a lamination film of gold film (Ni-P) film/Ni film P film Au film, and a lamination film of Au film Pt film Au film.
- 3. (Cancelled)
- 4. (Currently Amended) The mirror according to claim 31, wherein said material is one of a resin composition containing an active energy line polymerization initiator and

an active energy line reaction resin.

- 5. (Original) The mirror according to claim 4, wherein said active energy line reaction resin is one of phenol novolak type epoxy resin, cresol/volak type epoxy resin, glycylamine type epoxy resin and biphenyl type epoxy resin.
- 6. (Original) The mirror according to claim 1, wherein said mirror has a shape of a pyramid or a triangular pole, in which both ends are cut down.
- 7. (Original) The mirror according to claim 6, wherein said reflection surface plane is flat.
- 8. (Original) The mirror according to claim 6, wherein said reflection surface plane is a curved recess surface.
- (Original) The mirror according to claim 1, further comprising:
 a connection film portion orthogonal to an optical axis.
- 10. (Currently Amended) A mirror comprising a gold layer, wherein said gold layer has a reflection surface plane and a contact plane,

an angle between said reflection surface plane and said contact plane is 45° or equal to an angle between (100) plane orientation and a (111) plane orientation in a silicon crystal and

11. (Original) The mirror according to claim 10, wherein said mirror comprises one of said gold film, a lamination film of rhodium film - nickel film - said gold film, a lamination film of platinum film - nickel film - said gold film, a lamination film of palladium film - nickel film - said gold film, a lamination film of gold film - nickel film - said gold film, a lamination film of nickel film - boron alloy film - nickel film - said gold film, a lamination film of nickel film - said gold film, a lamination film of chrome film - nickel film - said gold film, a lamination film of gold film - (Ni-P) film/Ni film - P film - said gold film, and a lamination film of gold film - Pt film - said gold film.

12. (Cancelled)

- 13. (Currently Amended) The mirror according to claim $\frac{1210}{10}$, wherein said material is one of a resin composition containing an active energy line polymerization initiator and an active energy line reaction resin.
- 14. (Original) The mirror according to claim 13, wherein said active energy line reaction resin is one of phenol novolak type epoxy resin, cresol/volak type epoxy resin, glycylamine type epoxy resin and biphenyl type epoxy resin.
- 15. (Original) The mirror according to claim 10, wherein said mirror has a shape of a pyramid or a triangular pole, in which both ends are cut down.

- 16. (Original) The mirror according to claim 15, wherein said reflection surface plane is flat.
- 17. (Original) The mirror according to claim 15, wherein said reflection surface plane is a curved recess surface.
- 18. (Original) The mirror according to claim 10, further comprising: a connection film portion orthogonal to an optical axis.
- 19. (Currently Amended) An optical circuit comprising:

a substrate;

an optical fiber or an optical waveguide provided for said substrate; a photodiode or a surface emission type laser provided for said substrate; and a mirror connected with said substrate,

wherein said mirror comprises a multi-layer thin film, which comprises a first layer and a second layer,

said first layer is a reflection surface plane, said second layer has a contact plane with a substrate,

an angle between said reflection surface plane and said contact plane is 45° or equal to an angle between (100) plane orientation and a (111) plane orientation in a silicon crystal and

20. (Original) The optical circuit according to claim 19, further comprising: at least a cantilever of said substrate, wherein said mirror is installed in a tip portion of said at least a cantilever; and

an expanding and contracting member which moves said tip portion upwardly and downwardly.

- 21. (Original) The optical circuit according to claim 20, wherein said expanding and contracting member is one of a piezoelectric element, an electric distortion actuator, a magnetic distortion actuator, and a phase transition material.
- 22. (Original) The optical circuit according to claim 19, wherein said mirror comprises one of a gold film, a lamination film of rhodium film nickel film gold film, a lamination film of platinum film nickel film gold film, a lamination film of palladium film nickel film gold film, a lamination film of gold film nickel film gold film, a lamination film of nickel film boron alloy film nickel film gold film, a lamination film of nickel film gold film, a lamination film of chrome film nickel film gold film, a photosensitive polyimide film, a lamination film of gold film (Ni-P) film/Ni film P film Au film, and a lamination film of Au film Pt film Au film.

23. (Cancelled)

- 24. (Currently Amended) The optical circuit according to claim 2319, wherein said material is one of a resin composition containing an active energy line polymerization initiator and an active energy line reaction resin.
- 25. (Original) The optical circuit according to claim 24, wherein said active energy line reaction resin is one of phenol novolak type epoxy resin, cresol/volak type epoxy resin, glycylamine type epoxy resin and biphenyl type epoxy resin.
- 26. (Original) The optical circuit according to claim 19, wherein said mirror has a shape of a pyramid or a triangular pole, in which both ends are cut down.
- 27. (Original) The optical circuit according to claim 26, wherein said reflection surface plane is flat.
- 28. (Original) The optical circuit according to claim 26, wherein said reflection surface plane is a curved recess surface.
- 29. (Original) The optical circuit according to claim 19, further comprising: a connection film portion orthogonal to an optical axis.
- 30. (Currently Amended) An optical circuit comprising:a substrate;an optical fiber or an optical waveguide provided for said substrate;

a photodiode or a surface emission type laser provided for said substrate; and a mirror jointed with said substrate,

wherein said mirror comprises a gold layer, which comprises a reflection surface plane and a contact plane,

an angle between said reflection surface plane and said contact plane is 45° or equal to an angle between (100) plane orientation and a (111) plane orientation in a silicon crystal and

said mirror has a concave portion which is filled with a material.

31. (Original) The optical circuit according to claim 30, further comprising: at least a cantilever of said substrate, wherein said mirror is installed in a tip portion of said at least a cantilever; and

an expanding and contracting member which moves said tip portion upwardly and downwardly.

- 32. (Original) The optical circuit according to claim 31, wherein said expanding and contracting member is one of a piezoelectric element, an electric distortion actuator, a magnetic distortion actuator, and a phase transition material.
- 33. (Original) The optical circuit according to claim 30, wherein said mirror comprises one of a gold film, a lamination film of rhodium film nickel film gold film, a lamination film of platinum film nickel film gold film, a lamination film of palladium film nickel film gold film, a lamination film of gold film nickel film gold

film, a lamination film of nickel film - boron alloy film - nickel film - gold film, a lamination film of nickel film - gold film, a lamination film of chrome film - nickel film - gold film, a photosensitive polyimide film, a lamination film of gold film - (Ni-P) film/Ni film - P film - Au film, and a lamination film of Au film - Pt film - Au film.

34. (Cancelled)

- 35. (Currently Amended) The optical circuit according to claim 3430, wherein said material is one of a resin composition containing an active energy line polymerization initiator and an active energy line reaction resin.
- 36. (Original) The optical circuit according to claim 35, wherein said active energy line reaction resin is one of phenol novolak type epoxy resin, cresol/volak type epoxy resin, glycylamine type epoxy resin and biphenyl type epoxy resin.
- 37. (Original) The optical circuit according to claim 30, wherein said mirror has a shape of a pyramid or a triangular pole, in which both ends are cut down.
- 38. (Original) The optical circuit according to claim 37, wherein said reflection surface plane is flat.
- 39. (Original) The optical circuit according to claim 37, wherein said reflection surface plane is a curved recess surface.

40. (Original) The optical circuit according to claim 30, further comprising: a connection film portion orthogonal to an optical axis.